

NBS TECHNICAL NOTE 993

U.S. DEPARTMENT OF COMMERCE / National Bureau of Standards

Optical Material Characterization Final Technical Report February 1, 1978-September 30, 1978

QC 100 .U5753 IN0.993 1979 C.2

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National Bureau of Standards MAR 2 1979

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QC100 105753 101793 1979 0.2

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Advanced Research Projects Agency Arlington, Virginia 22209



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Issued February 1979

National Bureau of Standards Technical Note 993 Nat. Bur. Stand. (U.S.), Tech. Note 993, 71 pages (Feb. 1979) CODEN: NBTNAE

> U.S. GOVERNMENT PRINTING OFFICE WASHINGTON: 1979

For sale by the Superintendent of Documents, U.S. Government Printing Office, Washington, D.C. 20402 Stock No. 003-003-02031-1 Price \$2.40 (Add 25 percent additional for other than U.S. mailing)

OPTICAL MATERIALS CHARACTERIZATION

Albert Feldman, Deane Horowitz, Roy M. Waxler, and Marilyn J. Dodge

Ceramics, Glass and Solid State Science Division Center for Materials Science National Bureau of Standards

ARPA Order No	2620, 3343*
*Support obtained through Department of the Nav Naval Weapons Center	Y,
Program Code Number	4D10
Effective Date of Contract	January 1, 1974
Contract Expiration Date	September 30, 1978
Principal Investigator	Albert Feldman (301) 921-2840

Partial support for the work on piezo-optic constants of the alkaline-earth fluorides was provided by the Air Force Office of Scientific Research, Air Force Systems Command, USAF, under Grant No. AFOSR-ISSA-78-0026.

The views and conclusions contained in this document are those of the authors and should not be interpreted as necessarily representing the official policies, either expressed or implied, of the Advanced Research Projects Agency or the U.S. Government.

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Abstract

Data obtained as part of the Optical Materials Characterization Program are summarized in this report. Room temperature values of refractive index as a function of wavelength are presented for the following materials: commercially grown KC1, reactive atmosphere processed (RAP) KC1, KC1 nominally doped with 1.5% KI, hot forged CaF₂, fusion cast CaF₂, CaF₂ doped with Er (0.001% to 3% Er), SrF₂, chemical vapor deposited (CVD) ZnSe (2 specimens), and ZnS (CVD, 2 specimens). Data for the thermo-optic constant (dn/dT) and the linear thermal expansion coefficient are given for the following materials over the temperature range -180 °C to 200 °C: Al₂O₃, BaF₂, CaF₂, CdF₂, KBr, KC1, LiF, MgF₂, NaC1, NaF, SrF₂, ZnS (CVD), and ZnSe (CVD). The piezo-optic constants of the following materials are presented: As₂S₃ glass, CaF₂, BaF₂, Ge, KC1, fused SiO₂, SrF₂, a chalcogenide glass (Ge 33%, As 12%, Se 55%) and ZnSe (CVD).

Key words: Al₂O₃; As₂S₃ glass; BaF₂; CaF₂; CdF₂; chalcogenide glass; elastic compliances; elastic constants; elasto-optic constants; fused silica; Ge; hot forged; KBr; KCl; KCl:KI; LiF; MgF₂; NaCl; NaF; piezo-optic constants; refractive index; SiO₂; SrF₂; thermal expansion coefficient; thermo-optic constant; ZnS; ZnSe

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1. Technical Report Summary

1.1 Technical Problem

Windows subjected to high-average-power laser radiation will undergo optical and mechanical distortion due to absorptive heating. If the distortion becomes sufficiently severe, the windows become unusable. Theoretical calculations of optical distortion in laser windows depend on the following material parameters; absorption coefficient, refractive index, the thermo-optic constant (change of index with temperature), linear thermal expansion coefficient, stress-optical constants, elastic compliances, specific heat, thermal conductivity and density. Our program has been established to measure refractive indices, thermo-optic constants, piezo-optic constants, elastic compliances, and linear thermal expansion coefficients of candidate laser window materials.

1.2 General Methodology

Laboratory experiments are conducted for measuring refractive indices, thermo-optic constants, piezo-optic constants, elastic compliances and linear thermal expansion coefficients.

The refractive indices of prismatic specimens are measured on precision spectrometers by the method of minimum deviation. Two spectrometers are used. One instrument, which uses glass optics, is used for measuring refractive indices in the visible with an accuracy of several parts in 10⁶. The other instrument, which uses mirror optics, is used for measuring refractive indices in the ultraviolet and the infrared to an accuracy of several parts in 10⁵. Using both spectrometers we can measure refractive indices over the spectral region 0.2 μ m to 50 μ m.

We measure the linear thermal expansion coefficient, α , by the method of Fizeau interferometry. The interferometer consists of a specially prepared specimen which separates two flat plates. Interference fringes are observed due to reflections of HeNe laser radiation at 0.6328 µm from the plate surfaces in contact with the specimen. We obtain α by measuring the shift of these interference fringes as a function of temperature. We can measure α from -180 °C to 800 °C.

The thermo-optic constant, dn/dT, is measured by two methods. In the first method, we measure the refractive index with the precision spectrometers at two temperatures, 20 °C and 30 °C, by varying the temperature of the laboratory. This provides us with a measure of dn/dT near room temperature. In the second method, which may be used for measuring dn/dT from -180 °C to 800 °C, we obtain dn/dT from a knowledge of the expansion coefficient and by measuring the shift of Fizeau fringes in a heated specimen as a function of temperature. The Fizeau fringes are due to interferences between reflections from the front and back surfaces of the specimens. Measurements are made with discrete spectral sources, such as lasers or spectral lamps, in the infrared, the visible, and the ultraviolet.

We measure piezo-optic constants and elastic compliances using a combination of Twyman-Green and Fizeau interferometers. The coefficients for piezo-birefringence are measured by polarimetric techniques. From the shift of fringes in specimens subjected to uniaxial or hydrostatic compression, we obtain the data necessary for determining all the piezo-optic constants and elastic compliances. The measurement are made with discrete spectral sources.

In materials with small piezo-optic constants or in materials that cannot withstand large stresses, we use interferometers designed to measure fractional fringe shifts. At 10.6 μ m a modified Twyman-Green interferometer, which has a sensitivity of 0.01 λ , is used. At 632.8 nm, a modified Dyson interferometer, which has a sensitivity of 0.002 λ , is used. When using these interferometers to measure piezo-optic constants we must know the elastic constants of the material under test.

1.3 Technical Results

The purpose of this report is to collect in one publication all the data obtained under the Optical Materials Characterization Program. In addition to data found in our previous reports, we present data not yet reported. The data are tabulated in Section 2.9.

Section 2.1 discusses the measurement of refractive index by the method of minimum deviation. Tables of room temperature values of refractive index are presented as a function of wavelength. Also given are the parameters for a three term Sellmeier equation for refractive index. Data are given for the following materials: commercially grown KCl; reactive atmosphere processed (RAP) KCl; KCl nominally doped with 1.5% KI; hot forged CaF₂; fusion cast CaF₂; CaF₂ doped with the following percentages of Er: 0.001%, 0.003%, 0.01%, 0.03%, 0.01%, 0.03%, 0.1%, 0.3%, 1% and 3%; chemical vapor deposited (CVD) ZnSe (2 specimens); and CVD ZnS (2 specimens).

The measurement of linear thermal expansion coefficient is discussed in Section 2.2. A table of linear thermal expansion coefficients as a function of temperature over the temperature -180 °C to 200 °C is given for the following materials: Al_2O_3 , BaF_2 , CaF_2 , CdF_2 , KBr, KCl, LiF, MgF₂, NaCl, NaF, SrF₂, ZnS (CVD), and ZnSe (CVD). The data are a synthesis of values from the literature and values obtained under this program. Our data are presented when disagreement with the literature was found. Graphs are shown to demonstrate the discrepancies.

The measurement of thermo-optic constants is discussed in Section 2.3. Tables of thermo-optic constants as a function of temperature over the temperature range -180 °C to 200 °C are presented. In the following table, the materials and wavelengths for which data are presented are denoted by x's:

Material/Wavelength	0.458 µm	0.6328 µm	1.15 µm	3.39 µm	10.6 µm
Al ₂ O ₃	х				
BaF ₂	х	x	x	x	x
CaF ₂	х	x	х	x	
CdF2	х	x	x	x	
KBr (RAP)	x	x	х	x	х
KCl (RAP)	х	x	x	x	х
LiF	х	x	x	x	
MgF ₂	x	x	x	x	
NaCl	x	x	x	x	
NaF	x	x	x	x	
SrF ₂	x	х	x	x	x
ZnS (CVD)	·		x	x	x
ZnSe (CVD)		x	x	x	x

The measurement of piezo-optic constants and elastic compliances is discussed in Section 2.4. The piezo-optic constants of the following materials are given: As_2S_3 glass, BaF_2 , CaF_2 , Ge, KCl, fused SiO₂, SrF₂, a chalcogenide glass (Ge 33%, As 12%, Se 55%) and ZnSe (CVD).

1.4 Department of Defense Implications

The Department of Defense is currently constructing high-power laser systems. Criteria are needed for determining the suitability of different materials for use as windows in these systems. The measurements we perform provide data that laser system designers can use for determining the optical performance of candidate window materials.

1.5 Implications for Further Research

While extensive measurements of refractive properties have been made in the infrared, there remains a significant lack of data in the ultraviolet. A review of the literature indicates that piezo-optic data in the ultraviolet are virtually nonexistent and although some thermo-optic data are available, they are scant. These data would be particularly important for materials to be used in conjunction with excimer lasers (XeF, KrF, ArF).

2. Technical Report

2.1 Introduction

With the development of new laser systems of ever increasing average-power levels, the optical elements in these systems, even if they possess extremely small absorption coefficients, can experience a significant temperature rise. The temperature distribution in the element will generally be nonuniform; hence, an optical beam propagating through the element will experience a wavefront distortion due to the thermally induced optic path variation across the aperture of the element. Theoretical analyses [1-4] have shown that the variation of optic path will depend on: (1) the change of refractive index with temperature, (2) the change of element thickness due to thermal expansion, (3) the change of refractive index due to stresses produced by thermal gradients and, (4) the change of thickness due to these stresses. In order to predict the magnitude of these effects, the optical designer requires certain material parameters which include absorption coefficient, refractive index n, thermooptic constant dn/dT, piezo-optic constants q_{ij} , linear thermal expansion coefficient α , and elastic constants c_{ij} or s_{ij} . The purpose of the Optical Materials Characterization $program at the National Bureau of Standards has been to measure n, dn/dT, <math>q_{ij}$, α , and, when necessary s_{ij} of important optical materials of potential application in high-power laser

systems. An earlier examination of the literature had shown that data on dn/dT and $q_{...}$ of important optical materials were almost nonexistent outside the visible region of the spectrum [5]; hence, our program has emphasized measurements in the infrared at 10.6 µm and 3.39 µm, wavelengths close to the output of CO₂ and DF lasers, respectively.

This report discusses the various techniques we use for measuring n, dn/dT, α , q_i, and s_{ij}. It then summarizes, principally in tabular form, data we have obtained on a wide variety of infrared transmitting materials.

2.2 Refractive Index

Several techniques are used for measuring the refractive indices of optical materials; however, as part of this program, the measurements of n have been conducted on two precision spectrometers by the method of minimum deviation [6,7]. Schematic diagrams of both spectrometers are shown in Figure 1. The first spectrometer, which contains glass optics, is capable of measuring n in the visible and in the near infrared to an accuracy of several parts in 10^6 . The second spectrometer, which contains mirror optics, is capable of measuring n from 200 nm in the ultraviolet to 50 µm in the infrared to an accuracy of several parts in 10^6 . The accuracy depends on specimen quality and size. All values of refractive index are measured relative to the refractive index of air, n, that is we measure n/n. The value of n is about 1.0003 over the full wavelength range of measurement.

When determining the refractive index by the minimum deviation technique, collimated radiation is passed through a specimen which is in the form of a triangular prism. The prism is rotated about an axis parallel to the prism apex until a position is found where the angular deviation of the beam at a chosen wavelength is a minimum. In terms of the minimum deviation angle D, the angle between the emergent beam and an undeviated beam, and the prism angle A, the refractive index is given by

$$n = \frac{\sin \frac{D+A}{2}}{\sin \frac{A}{2}}$$
(1)

Measurements are performed at discrete wavelengths which are selected from the emission spectra of Hg, Cd, He, Cs, and Zn and from calibrated absorption bands of H₂O, polystyrene, methycyclohexane, and 1,2-4 trichlorobenzene. A series of calibrated narrow-band filters is also used in the infrared region. Each set of experimental data is fitted by a least squares solution to a three term Sellmeier-type dispersion equation of the form [8]

$$n^{2} - 1 = \sum_{j=1}^{3} \frac{A_{j}\lambda^{2}}{\lambda^{2} - \lambda_{j}^{2}}$$
(2)



Figure 1. (a) Schematic of spectrometer used for visible region
refractometry. (b) Schematic of spectrometer used for nonvisible region refractometry. Symbols: A = source,
B = divided circle, C = prism table, D = collimator,
E = telescope, F = collimating mirror, G = movable mirror,
H = detector.

where λ is the wavelength of interest, λ_{j} is the wavelength position of an oscillator, and A is the oscillator strength. The λ_{j} 's and A's are not intended to have any physical significance because they can be influenced by the wavelength range of the experiment data. Primary emphasis is given to procuring a mathematical fit to the measured data useful for interpolation. Equation (2) is not adequate for fitting data close to an absorption edge.

It is possible to obtain dn/dT by measuring n at two temperatures, usually near 20 °C and 30 °C (strictly speaking we obtain $\Delta n/\Delta T$). What we actually obtain is $d(n/n_{_{_{_{_{_{_{}}}}}})/dT$ where

$$\frac{d}{dT} \left(\frac{n}{n}\right) \stackrel{\sim}{=} \frac{dn}{dT} - n \frac{dn}{dT}$$
(3)

where $\frac{dn}{dT}$ is about 1.1 x 10⁻⁶ K⁻¹ [9]. The particular application of the data will determine whether the corrections in eq. (3) should be considered. For example, if the optical component is always in thermal equilibrium with the surrounding air, the correction is unnecessary.

In Tables 1a through 1e (Section 2.9) we tabulate coefficients for computing refractive index from equation (2) for the following materials: Table 1a - commercial KC1, RAP KC1, and KC1:KI (KC1 nominally doped with 1.5% KI); Table 1b - hot forged and fusion cast CaF₂; Table 1c - SrF₂; Table 1d - CVD ZnS (2 specimens), and; Table 1e - CVD ZnSe (2 specimens).

In Tables 2a through 2f we present tabulations of refractive index at convenient wavelength intervals for the following materials: Table 2a, 2b, 2c-commercial KCl, RAP KCl, and KCl:KI; Table 2d, 2e- hot forged and fusion cast CaF₂; Table 2f - SrF₂; Table 2g, 2h - CVD ZnS (2 specimens); Table 2i, 2j - CVD ZnSe (2 specimens); and Table 2k - CaF₂ doped with the following percentage of Er: 0.001%, 0.003%, 0.01%, 0.03%, 0.1%, 0.3%, 1%, 3%. The values given apply to the specific specimens measured. Differences in the fourth decimal place may occur in nominally identical materials, as can be seen, for example, in the data for CVD ZnS and ZnSe.

2.3 Linear Thermal Expansion Coefficient

Different techniques have been used to measure linear thermal expansion. The most common technique employs a quartz dilatometer, but this measurement is not of great accuracy. A second technique involves the measurement as a function of temperature of lattice parameters by x-ray techniques [10]. In a third technique, α is obtained from a measurement of the capacitance of a parallel plate capacitor, where the plate spacing is a function of the specimen thickness [11]. We measure α by an interferometric technique [12]. A specially prepared specimen is placed between two optic flats as shown in Figure 2. Fizeau interference figures are observed when monochromatic radiation from a helium-neon laser (λ =0.6328 µm) is reflected from the two surfaces in contact with the specimen. These fringes are observed to shift as a function of temperature due to the thermal expansion of the specimen.

Figure 3 shows a schematic diagram of the apparatus used for measuring both α and dn/dT. This apparatus will operate over the temperature range -180 °C to 200 °C. The furnace is constructed from a cylinder of copper 37 mm in diameter by 75 mm high with walls 6 mm thick to permit rapid transfer of heat. A commercial band heater, which is clamped around the furnace generates 175 W of heat with an input of 120 VAC.

The furnace rests at the bottom of an evacuable chamber 100 mm in diameter by 150 mm tall. Protruding from the bottom is a copper rod, 12 mm in diameter by 150 mm long, that conducts heat away from the furnace to the liquid nitrogen reservoir. Thus, we can stabilize the temperature in the furnace by Lalancing the heat input from the heater with the heat leak to the liquid nitrogen.







Figure 3. Apparatus for measuring linear thermal expansion and thermooptic constants as a function of temperature over the range -180 °C to 200 °C. The specimen rests within the furnace over a depression that is milled at an angle of 1° with respect to the furnace axis in order to deflect extraneous laser beam reflections to the side. Holes are drilled at several locations within the furnace to allow placement of thermocouples in contact with the specimen and to allow the pressure within the furnace to equalize with the pressure outside the furnace. Two thermocouples measure the temperature at the top and at the bottom of the specimen. A copper cover with a window allows access of laser radiation to the specimen in the furnace while maintaining a uniform thermal environment around the specimen. All windows in the system are tilted at a 1° angle to eliminate unwanted reflections.

We find that the system operates well when filled with a helium exchange gas of several millimeters Hg pressure. The helium environment has several advantages over air or vacuum. During cool-down, products in the air condense on the system optics and hence interfere with the laser beam. With vacuum, the thermal response of the system is sluggish because of poor heat transfer between the furnace, the heat leak, and the specimen. In addition, there is a large temperature difference between the two thermocouples. With the helium present, the maximum temperature differential measured with the two thermocouples across a 12 mm thick specimen is less than 1 K at a given mean temperature.

The procedure used for measuring α consists of first cooling the specimen to approximately liquid nitrogen temperature. Sufficient time is allowed for the two thermocouple readings to agree to within 1 K. The furnace is then heated very slowly until a fringe minimum is observed on a strip chart recorder monitoring the Fizeau intensity. The temperature is then recorded. Subsequently, the furnace is heated rapidly and after a convenient number of fringes has been observed, power to the furnace is cut back to allow the thermocouple readings to equilibrate while the temperature is slowly rising. At a fringe minimum, the temperature is recorded. The heating process is repeated until the maximum desired temperature is achieved.

The linear thermal expansion coefficient is defined by

$$\alpha = \frac{1}{t_{o}} \frac{dt}{dT}$$
(4)

where t is the room temperature specimen thickness and t is the specimen thickness at temperature T. In terms of a fringe count N, at a temperature T, we calculate α (T) by the formula

$$\alpha(\mathbf{T}) = \frac{\lambda}{2t_o} \frac{\mathbf{N}_i - \mathbf{N}_{i-1}}{\mathbf{T}_i - \mathbf{T}_{i-1}}$$
(5)

where $T = (T_i + T_{i-1})/2$. A graph is then made of α as a function of T. On this graph we also plot either the accepted handbook values of $\alpha(T)$ when they are available, or else values from the literature. A curve is then visually drawn through the data and from this curve, we abstract a set of data points. These points are then fitted by computer to a polynominal. The purpose of the fit is to obtain an analytical expression for $\alpha(T)$, which is needed for computing dn/dT as a function of temperature.

In Table 3, we present values of α from -180 °C to 200 °C at 20 ° temperature intervals for Al₂O₃ (only perpendicular to c-axis, α_{\perp}), BaF₂, CaF₂, CdF₂, KBr, KCl, LiF, MgF₂ (both α_{\perp}), NaCl, NaF, SrF₂, CVD ZnS, and CVD ZnSe. In the cases of NaCl and NaF there is disagreement between published values [13] and our values (see figures 4 and 5); we list only our values. We have confidence in our values because our results are in excellent agreement with the bulk of the measurements reported in the literature. We did not measure the linear thermal expansion coefficient of Al₂O₃; hence, the numbers shown were computed from values in the American Institute of Physics Handbook [13].

Figures 4 and 5 show the discrepancies betweeen our values (triangles and dashed lines) and values in the literature (circles and solid lines) for NaCl and NaF, respectively. In Figures 6 and 7, we show curves of α as a function of temperature for CdF₂ and MgF₂, respectively. The triangles and solid curves are our data. In the case of CdF₂, there has been virtually no earlier published data. In the case of MgF₂, we find excellent agreement with recently obtained low temperature data [11] but agreement with others [10,14] is poor above room temperature.



Figure 4. Linear thermal expansion coefficient of NaCl as a function of temperature. The triangles are our experimental data and the circles are from the AIP Handbook [13].



Figure 5. Linear thermal expansion coefficient of NaF. The triangles are our experimental data and the circles are from the AIP Handbook [13].



Figure 6. Linear thermal expansion coefficient of CdF_2 as a function of temperature. The triangles show our experimental data and the single circle is from S. S. Ballard and J. S. Brow-der, Appl. Opt. 5, 1873 (1966).



Figure 7. Linear thermal expansion coefficients of single crystal MgF₂ as a function of temperature. The upper curve is for $\alpha_{||}$; the lower curve is for α_{\perp} . || and \perp refer to parallel and perpendicular to the c axis, respectively. The curves and triangles are our data; the squares are from Ref. [11], the circles from Ref. [10], and the x's from [14].

2.4 The Thermo-optic Constant

The thermo-optic constant, dn/dT, is measured by an interferometric technique at discrete laser wavelengths over the temperature range -180 °C to 200 °C. With this technique, we observe as a function of temperature the shift of Fizeau interference fringes formed from reflections off the surfaces of an optical specimen polished plane parallel. The same apparatus and experimental technique used for measuring α is used for measuring dn/dT. The change of index from room temperature to temperature T_i is given by

$$\Delta n(T_{i}) = \left(\frac{M_{i}\lambda}{2t_{o}} - n_{o}\frac{\Delta t}{t_{o}}\right) (1 + \frac{\Delta t}{t_{o}})^{-1}$$
(6)

where M_i is the fringe count from room temperature to temperature T_i, n is the room temperature refractive index, and $\Delta t/t$ is computed at temperature T_i from the linear thermal expansion data. We obtain dn/dT (strictly speaking $\Delta n/\Delta T$) from

$$\frac{\mathrm{dn}\left(\mathrm{T}\right)}{\mathrm{dT}} = \frac{\Delta n\left(\mathrm{T}_{i}\right) - \Delta n\left(\mathrm{T}_{i-1}\right)}{\mathrm{T}_{i} - \mathrm{T}_{i-1}} \tag{7}$$

where $T = (T_{i} + T_{i-1})/2$.

Table 4 presents thermo-optic constants of the following materials over the temperature range -180 °C to 200 °C tabulated at 20 °C increments:

A12 ⁰ 3	- Table	4a	MgF ₂ - Table 4h
BaF 2	- Table	4b	NaCl - Table 4i
CaF ₂	- Table	4c	NaF - Table 4j
CdF2	- Table	4d	SrF ₂ - Table 4k
KBr	- Table	4e	ZnS(CVD) - Table 41
KCl	- Table	4f	ZnSe(CVD) - Table 4m
LiF	- Table	4q	

An intercomparison of some of these data with data in the literature has been made and reasonably good agreement was found [15].

In Table 5 we present refractive index and thickness data used for calculating dn/dT of the above-mentioned materials.

2.5 Piezo-optic Constants

The piezo-optic constants are the components of a fourth rank tensor that describe the effect of stress on the refractive index of a material [16]. The relationship is expressed by

$$\Delta(\kappa^{-1})_{ij} = q_{ijk\ell} \sigma_{k\ell}$$
(8)

where κ^{-1} is the reciprocal of the optical dielectric tensor, σ is the stress tensor, q_{ijkl} are the components of the piezo-optic tensor, and the indices, i, j, k, and ℓ take values 1, 2, and 3. Repeated indices indicate summation. Because both the stress and dielectric tensors are symmetric under interchange of indices, a contracted notation (also called the Voigt notation) has been adopted so that equation (8) becomes

$$\Delta(\kappa^{-1})_{m} = q_{mn} \sigma_{n}$$
(9)

where m and n take on values 1-6 corresponding to $ij \rightarrow m$, $kl \rightarrow n$ with $ll \rightarrow l$, $22 \rightarrow 2$, $33 \rightarrow 3$, 23 and $32 \rightarrow 4$, 13 and $31 \rightarrow 5$, and 12 and $2l \rightarrow 6$. Nye [16] discusses in detail the relationship between components in the full notation and in the contracted notation.

The elasto-optic constants relate the change of refractive index to strain in a material. These coefficients are related to the piezo-optic constants by

> p_{ij} = q_{im}c_{mj} (10)

where p_{ij} is a component of the elasto-optic tensor and c_{ij} is a component of the elastic stiffness tensor, both expressed in contracted notation. In this presentation, only the measurement of piezo-optic constants is discussed; however, by use of equation (10), it is a simple matter to convert to the elasto-optic constants.

In a crystalline material with the least symmetry there exist 36 independent piezo-optic coefficients. However, the materials that have been of interest to the NBS program have been of cubic or isotropic symmetry; hence, the discussion is limited to these materials. Most cubic materials possess three independent piezo-optic constants, q₁₁, q₁₂, q₄₄; isotropic materials have two independent constants, q_{11} and q_{12} , where $q_{44} = q_{11} - q_{12}$. Thus, we can

measure all these coefficients by measuring changes of n when stresses are applied along certain symmetry directions. If we apply a uniaxial compressive stress, P, along the [100] , axis of a cubic material (any axis of an isotropic material), the change of n will depend on the state of polarization of the radiation and is given by

> $\Delta n = \frac{n^3}{2} q P$ (11)

where $q = q_1$ for radiation polarized parallel to the stress axis and $q = q_1$ for radiation polarized perpendicular to the stress axis. This convention will be used throughout the following discussion.

The stress-induced birefringence (piezo-birefringence) for P along [100] is given by

$$\Delta n | | -\Delta n | = \frac{n^2}{2} (q_{11} - q_{12}) P$$
 (12)

and for P along [111] is given by

 $\Delta n_{||-\Delta n|} = \frac{n^3}{2} q_{44} P.$ (13)

Here | and | refer, respectively, to polarization parallel and perpendicular to the stress axis. Equations [11-13] provide more than enough conditions for obtaining all the piezooptic coefficients.

A variety of techniques have been employed for measuring the photoelastic constants of optical materials including acousto-optic scattering and Brillouin scattering. Many of these techniques have been reviewed recently [17]. In this article, we discuss the techniques used in the NBS measurements program. The techniques involve interferometric and polarimetric measurements on specimens under static uniaxial and hydrostatic stress. These measurements can provide data for obtaining not only the piezo-optic constants, but also elastic compliances.

Fizeau Interferometer: A specimen in the form of a right rectangular prism with dimensions approximately 12 x 12 x 36 mm is stressed parallel to the long dimension in a calibrated stressing frame [18] (see Figure 8). Two opposite rectangular faces of the prism are polished flat and parallel so that Fizeau interference fringes are observed when laser radiation is reflected from them. These fringes are observed to shift as a function of applied stress. If the stress is applied along the [100] crystallographic axis, the fringe shift per unit applied stress is

$$\frac{\Delta N}{\Delta P} = \frac{2t}{\lambda} \left(\frac{n^3}{2} q - n s_{12}\right).$$
(14)

where s₁₂ is a component of the elastic compliance tensor and q is defined above. If the specimen'is subjected to a hydrostatic compression, the fringe shift per unit applied pressure is

$$\frac{\Delta N}{\Delta P} = \frac{2t}{\lambda} \left[\frac{n^3}{2} (q_{11} + 2q_{12}) - n(s_{11} + 2s_{12}) \right].$$
(15)



Figure 8. Stressing apparatus. A = adjustment screw with domed tip, B = adjusting member threaded into push rod, C = lever arm, D = coil spring, E = axis, F = frame, G = spacer, H = ball bushing, I - stressing screw with domed tip, J = push rod, K = specimen cup, L = steel ball, M = load cell, N = specimen. The extra terms containing the elastic compliances on the right of equations (14) and (15) occur because the fringe shift is due to the change of optic path in the specimen, which depends both on the change of n and the change of specimen thickness.

Twyman-Green Interferometer: A specimen mounted in a calibrated stressing frame is placed in one arm of a Twyman-Green interferometer. When a stress is applied to the specimen the fringes at the output of interferometer are observed to shift. If the stress is applied along the [100] crystallographic axis, the fringe shift per unit applied stress is

$$\frac{\Delta N}{\Delta P} = \frac{2t}{\lambda} \left[\frac{n^3}{2} q - (n-1)s_{12} \right]$$
(16)

If all the measurements described by equations [14-16] are made, we can obtain not only q_{11} and q_{12} , but also s_{11} and s_{12} .

Modified Twyman-Green Interferometer. For many cases, especially in the infrared, it is difficult to obtain a shift of even one fringe by the above two methods. We then require a modified interferometric technique which is capable of measuring fractions of a fringe shift [19,20]. Figure 9 shows an interferometer that is capable of measuring 0.01 fringe shift at 10.6 µm. The two arms of the interferometer are in close proximity in order to minimize instabilities due to air currents and vibrations. The effects of vibrations are also minimized by mounting the diagonal mirror onto the same base as the beamsplitter and by mounting the two end mirrors on a common base. The end mirror in the specimen arm of the interferometer undergoes a sinusoidal translation along the optic axis, thus, modulating the output intensity of the interferometer. The reference specimen at 10.6 μm is a crystal of Ge in a compression appratus that we have calibrated by measuring the force necessary to produce an integral number fringe shift. Fractional fringes are then obtained by linear interpolation. In operation, the reference specimen is stressed until the interferometer is at a null, which occurs when the fundamental harmonic of the output intensity is zero. A given stress applied to the unknown specimen will shift the interferometer away from null, whereupon we compensate for this shift by applying an incremental stress to the Ge that brings the interferometer back to null. From these data we can calculate q_{11} and q_{12} with eq. (16) provided s_{12} is known. The state of the polarization is determined by the polarizer. The variable wave plate is used to balance the intensities of the two arms of the interferometer for a given state of polarization. It consists of a specimen of Ge placed in a stressing apparatus with the angle of stress at 45° with respect to the vertical in a plane perpendicular to the beam axis.

Modified Dyson Interferometer. We have constructed a polarizing interferometer for measuring photoelastic constants. This instrument is capable of measuring fringe shifts to a precision of λ /500 at 632.8 nm [21]. It is based on a design by Dyson [22] that was further modified by Green [23]. A schematic diagram of the experimental apparatus is shown in Figure 10. This instrument operates on two beam interference, however, the two beams are orthogonally polarized. Thus, an optic path change in one arm of the interferometer results in a change of state of polarization of the combined beam at the output of the interferometer. Hence, fringe shifts are analyzed with ellipsometric techniques which have great inherent precision.

This interferometer has several other advantages over conventional Twyman-Green interferometers: it is more stable with respect to motion of system elements because both beams traverse the same optics, hence, the optic path changes in both arms tend to be equal. In addition, the close proximity of the arms minimizes the effects of thermal currents, which are further reduced by placement of a cover over the interferometer part of the apparatus.

In this interferometer, the expression for the piezo-optic constant in terms of the fringe shift per unit applied stress is

$$q = \frac{2}{n^3} \left[\frac{\lambda}{t} - \frac{\Delta N}{\Delta P} + (n-1)s_{12} \right]$$
(17)

<u>Stress-Induced Birefringence (Piezo-Birefringence)</u>: The coefficients that determine stressinduced birefringence in most cubic materials are $q_{11}-q_{12}$ and q_{44} . It is most convenient to

measure these coefficients on two separate samples, one oriented for stress along [100] and the other oriented for stress along [111], because in these orientations the crystal becomes optically uniaxial and not biaxial; hence, small angular misorientations lead to only small measurement errors.







Figure 10. Modified Dyson interferometer for measuring piezo-optic constants in the visible.

A variety of techniques have been used to measure piezo-birefringence [17]. In the simplest technique, the specimen is placed between two crossed polarizers with the stress axis at 45° with respect to the direction of polarization and perpendicular to the radiation beam. As stress is applied, the output intensity will undergo a series of nulls corresponding to a series of fringe shifts and the fringe shift per unit applied stress is

$$\frac{\Delta N}{\Delta P} = \frac{tn^3}{2\lambda} q'$$
(18)

where $q' = q_{11} - q_{12}$ for stress along [100] and $q' = q_{44}$ for stress along [111]. In the case of noncubic materials, the expression for the fringe shift becomes much more complicated.

Frequently, it is either impossible or inconvenient to apply sufficient stress to obtain the shift of even one fringe. In this case, a compensator is placed within the experimental apparatus. Compensators used are Soleil compensators, de Senarmont compensators, or compensators consisting of a stressed specimen which acts like a Soleil compensator. Photometric techniques are also employed [24]. Recently, Birnbaum et al. [25] have developed an interesting new technique for measuring piezo-birefringence in which a stressed specimen is placed in a scanning Fabry-Perot cavity.

A simple variation of the basic crossed polarizer technique, is to double pass the radiation through the specimen [20]. This technique which has the advantage of requiring only one polarizer, has double the sensitivity of the single pass method. Figure 11 shows a double pass arrangement for measuring piezo-birefringence at 10.6 µm.

In Tables 6 through 11, we present photoelastic constant data for CaF_2 , SrF_2 , BaF_2 , As_2s_3 glass, a chalcogenide glass (Ge 33%, As 12%, Se 55%), Ge, KCl, KCl:KI, fused SiO₂, and CVD ZnSe. The ZnSe is a polycrystalline material and, hence, is considered to be isotropic. In Table 12, we present elastic constant data for BaF_2 , CaF_2 , Ge, KCl, fused SiO₂, SrF₂, and ZnSe (CVD).

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Figure 11. Double pass arrangement for measuring piezo-birefringence at 10.6 µm.

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2.7 Acknowledgements

We would like to thank the following for supplying materials for measurement: Carl Pitha of RADC, John Fenter and Colonel William Goldberg of AFML, Perry Miles of Raytheon, Ray Hilton, Philip Klein of NRL, E. Bernal G. of Honeywell, John Fontanella of the U. S. Naval Academy and B. Sherman of the Servo Corporation. We thank William McKean and Howard Layer of NBS for valuable assistance with instrumentation.

We appreciate encouragement provided for our program by A. H. Guenther of the Air Force Weapons Laboratory, A. J. Glass of the Lawrence Livermore Laboratory, H. E. Bennett and J. M. Bennett of the Naval Weapons Center, M. Stickley of the Department of Energy, H. Winsor of the Defense Advanced Research Projects Agency, and M. Swerdlow of the Air Force Office of Scientific Research.

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2.9 Tables

			1.
Specimen	Commercial	RAP ^a	KC1:KI ^D
Temperature	19.9 °C	20.2 °C	19.9 °C
A	0.74783561	0.80902239	0.78085271
A ₂	0.42626630	0.36511458	0.39493953
A ₃	4.6867104	2.2323342	2.2662238
$\lambda_1 (\mu m)$	0.083633417	0.08828162	0.08611153
$\lambda_2^{(\mu m)}$	0.15389978	0.15737774	0.15600595
λ ₃ (μm)	95.063422	65.870423	66.360157
No. of Waveleng	ths 79	58	54
Wavelength Rang	e (µm) 0.22-14.4	0.25-15.5	0.25-15.5
Average Absolut	e_		
Residual of n (10^{-5}) 2.3	2.9	3.2
•			

Table la. Constants of Dispersion Equation for KCl near 20 °C.

a Reactive atmosphere processed. b KCl nominally doped with 1.5% KI.

Table 1b. Constants of Dispersion Equation for CaF₂ near 20 °C.

Specimen Temperature	Hot Forged 20.8 °C	Fusion Cast 21.7 °C
A ₁	0 .9 8594551	0.34393190
A2	0.05290246	0.6948269
A ₃	4.2816899	3.8902192
$\lambda_1 (\mu m)$	0.07218116	0.0127821
λ_{2}^{\perp} (µm)	0 .1 4114719	0.0936663
$\lambda_3 (\mu m)$	36.465937	34.8259
No. of Wavelengths Wavelength Range	69 0.25-8.03	60 0.21-8.7
Average Absolute Residual of n (10 ⁻⁵)	1.9	2.1
Specimen	Fusion Cast	
---	-------------	--
Temperature	20 °C	
2	0.67005004	
A1	0.07805894	
A ₂	0.37140533	
A ₃	3.3485284	
λ ₁ (μm)	0.05628989	
$\lambda_2^{(\mu m)}$	0.10801027	
λ ₃ (μm)	39.906666	
No. of Wavelengths	53	
Wavelength Range (µm)	0.21-11.5	
Average Absolute Residual of n (10 ⁻⁵)	2.1	

Table 1c. Constants of Dispersion Equation for Fusion Cast SrF near 20 °C.

Table 1d. Constants of Dispersion Equation for Chemical Vapor Deposited (CVD) ZnS near 20 °C.

Specimen	#1	#2
Temperature	21.6 °C	21.9 °C
A	0.33904026	0.24199447
A	3.7606868	3.8575584
2	2 721 2252	0.540000
^A 3	2.7312353	2.5433609
λ ₁ (μm)	0.31423026	0.33005445
$\lambda_2 (\mu m)$	0.17594174	0.17899635
λ_{2} (µm)	33.886560	32.849275
No. of Wavelengths	25	30
Wavelength Range (µm)	0.55-10.6	0.55-10.6
Average Absolute 5		
Residual of n (10 ⁻³)	5.4	4.6

Specimen	#1	#2	
Temperature	20.3 °C	20.8 °C	
Al	4.2980149	4.4639521	
A2	0.62776557	0.46132463	
A ₃	2.8955633	2.8828867	
λ_{1} (µm)	0.19206300	0.20107634	
λ_2 (µm)	0.37878260	0.39210520	
$\lambda_3^{(\mu m)}$	46.994595	47.047590	
No. of Wavelengths Wavelength Range (µm)	33 0.54-18.2	38 0.54-18.2	
Average Absolute Residual of n (10 ⁻⁵)	6.2	4.1	

Table le. Constants of Dispersion Equation for Chemical Vapor Deposited (CVD) ZnSe near 20 °C. Refractive Index of Commercial KCl at Discrete Wavelengths (T = 19.9 °C). Table 2a.

(mп) ү	ц	(hm) У (hm)	u	ү (тт)	ц
8.25	1.59010	8.95	1.48019	7.50	1.46459
8.38	1.54574	1.00	1.47959	8,00	1.46319
8.35	1.52365	1.50	1.47642	8,50	1.46169
8.48	1.51072	2.00	1.47508	99.6	1.46010
6.45	1.50240	2.50	1.47422	9.50	1.45842
8.58	1.49670	3.00	1.47348	10.00	1.45664
0.55	1.49260	3,50	1.47275	10.50	1.45477
9.69	1.48955	4.60	1.47199	11.00	1.45280
6.65	1.48721	4.50	1.47117	11.50	1.45073
9.79	1.48537	5,00	1.47028	12.60	1.44856
0.75	1.48390	5,50	1.46931	12.50	1.44629
0.80	1.48271	6.60	1.46826	13.60	1.44391
6.85	1.48172	6.50	1.46712	13.50	1.44143
6.98	1.48089	7.00	1.46590	14.00	1.43885

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g	1.46169	1.46609	1.45839	1.45658	1.45467	1.45266	1.45054	1.44831	1.44597	1.44352	1.44095	1.43826	1.43545	1.43252	
γ (hm)	8.50	9.60	9.50	10.90	10.50	11.60	11.50	12.00	12.50	13.00	13.50	14.00	14.50	15.00	
ц	1.47961	1.47643	1.47510	1.47424	1.47350	1.47278	1.47202	1.47120	1.47031	1.46934	1.46829	1.46716	1,46593	1.46461	
(mπ) γ	1.00	1.50	2.90	2.50	3.60	3.58	4.60	4.50	5.00	5.50	6.00	6.50	7.88	7.50	
и	1.59029	1.54577	1.52367	1.51075	1.58243	1.49673	1.49263	1.48957	1.48723	1.48540	1.48392	1.48273	1.48174	1.48091	
(mu) ک ا	8.25	9,30	6,35	0.49	8.45	0.50	0.55	0.69	8.65	6.70	6.75	8.88	8.85	0.50	

Table 2c. Refractive Index of KC1:KI (1.5% KI) at Discrete Wavelengths (T = 19.9 °C).

(un) ү	ц	(μμ) γ	ц	γ (nm)	Ę
8.25	1.59146	1.88	1.48619	8.50	1.46226
B. 3B	1.54669	1.50	1.47700	9.90	1.46066
8.35	1.52445	2.60	1.47567	9.50	1.45895
0.40	1.51146	2,50	1.47480	16.90	1.45715
0.45	1.58310	3, 88	1.47406	10.50	1.45524
6.50	1.49737	3,50	1.47334	11.00	1.45323
6.55	1.49326	4.00	1.47258	11.50	1.45112
9,69	1.49019	4.50	1.47176	12.60	1.44889
6.65	1.48784	5.60	1.47087	12.50	1.44656
6.70	1.48599	5.50	1.46991	13.00	1.44411
0.75	1.48452	6.60	1.46886	13.50	1.44154
6.89	1.48332	6.50	1.46772	14.60	1.43886
6.85	1.48232	7.00	1.46649	14.50	1.43605
6.99	1.48149	7.50	1.46518	15.00	1.43312
6.95	1.48079	8.99	1.46377	15.50	1.43006

Table 2d. Refractive Index of Hot Forged CaF_2 at Discrete Wavelengths (T = 20.8 °C).

u u	<u>γ (μm)</u>	u	<u>ү (µш)</u>	u
1.46730	0.75	1.43112	3.50	1.41402
1.45399	0.80	1.43055	4.00	1.40961
1.44652	0.85	1.43006	4.50	1.40458
1.44185	0.96	1.42963	5.00	1.39891
1.43872	0.95	1.42925	5,50	1.39258
1.43649	1.60	1.42890	6.90	1.38556
1.43485	1.50	1.42627	6.50	1.37782
1.43358	2.60	1.42386	7.00	1.36933
1.43259	2.50	1.42110	7.50	1.36005
1.43178	3.60	1.41784	8.00	1.34995

Table 2e. Refractive Index of Fusion Cast CaF_2 at Discrete Wavelengths (T = 21.7 °C).

(nm) Υ	q	у (µш)	ц	у (лт)	ч
0.25	1.46728	0.80	1.43054	4.50	1.40464
8.38	1.45401	0.85	1.43006	5.00	1.39897
8.35	1.44652	6.90	1.42963	5,50	1.39264
0.40	1.44184	0.95	1.42925	6.00	1.38561
8.45	1.43870	1.00	1.42890	6.50	1.37786
0.59	1.43647	1.50	1.42628	7.00	1.36934
8, 55	1.43483	2,00	1.42388	7.50	1.36003
8.68	1.43357	2.50	1.42112	8.60	1.34987
6.65	1.43257	3.69	1.41787	8,50	1.33881
0.70	1.43177	3.50	1.41406		
0.75	1.43111	4.00	1.40966		

20 0 0C F, Table 2f. Refractive Index of Fusion Cast SrF. at Discrete Wavelengths

- 			12 ac Discrete Mave	elenyuns (l = 20.	· (-) ·
(uп') Y	n	<u>λ (μm)</u>	u	у (лт)	n
8.25	1.47336	0.90	1.43382	6.50	1.39941
8.38	1.45922	0.95	1.43346	7.60	1.39402
B . 35	1.45131	1.00	1.43314	7.50	1.38816
8.48	1.44639	1.50	1.43095	8.60	1.38180
6.45	1.44309	2.60	1.42922	8.50	1.37493
6.58	1.44077	2.50	1.42734	9.60	1.36752
6.55	1.43906	3.00	1.42519	9.50	1.35955
0.69	1.43776	3.50	1.42269	16.69	1,35699
0.65	1.43675	4.60	1.41982	10.50	1.34181
0.70	1.43593	4.50	1.41657	11.00	1.33198
6.75	1.43527	5.00	1.41291	11.50	1.32146
9.89	1.43471	5,50	1.40584		
6.85	1.43423	6.00	1.40435		

Idule zy.	Kerractive Index OT	LVU ZNS SPECT	men #i at Ulscrete	wavelengths (1 =	: 21.6 °C).
(hm)	n	<u>у (µm)</u>	u	<u>λ (μm)</u>	u
8.55	2.38579	1.50	2.27209	6.50	2.23583
8.68	2.36237	2.80	2.26453	7.00	2.23183
8.65	2.34509	2.50	2.26030	7.50	2.22749
8.70	2.33189	3.60	2.25719	8.60	2.22280
6.75	2.32155	3.50	2.25445	8.50	2.21775
6.38	2.31327	4.60	2.25178	9.00	2.21231
8.85	2.30652	4.50	2.24983	9.50	2.20645
6.98	2.30893	5, 66	2.24610	10.60	2.20016
6.95	2.29626	5.50	2.24294	16.50	2.19340
1.66	2.29230	6.00	2.23953		

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Table 2h. Refractive Index of CVD ZnS Specimen #2 at Discrete Wavelengths (T = 21.9 °C).

(mц) Х	u	(шп) ү	c	λ (μm)	Ę
8.55	2.38579	1.50	2.27286	6.50	2,23595
8.69	2.36232	2.60	2.26451	7.00	2.23196
0.65	2.34503	2,50	2.26029	7.50	2.22763
9.78	2.33184	3.60	2.25719	8.60	2.22296
8.75	2.32150	3.50	2.25447	8.50	2.21791
0.58	2.31322	4.00	2.25182	9,66	2.21246
8.85	2.30647	4.50	2.24907	9.50	2.20660
0.90	2.30089	5.00	2.24616	10.66	2.20029
0.95	2.29622	5.50	2.24303	10.50	2.19351
1.68	2.29226	6.00	5, 23963		

Refractive Index of CVD ZnSe Specimen #1 at Discrete Wavelengths (T = 20.3 °C). Table 2i.

(mu) y	c	(mт) Х	ч	λ (μm)	q
8.55	2.66246	4.00	2.43316	11.50	2.39650
8.68	2.61380	4.50	2.43132	12.00	2.39281
0.65	2.58054	5.00	2.42953	12.50	2.38892
8.7 8	2.55636	5.50	2.42772	13.60	2,38481
0.75	2.53804	6.00	2.42584	13.50	2.38648
8.89	2.52373	6.50	2.42388	14.00	2.37593
9,85	2.51230	7.60	2.42181	14.50	2.37114
6.56	2.58298	7.50	2.41961	15.00	2.36610
8.95	2.49528	8.00	2.41728	15.50	2.36880
1.69	2.48882	8.50	2.41481	16.00	2,35523
1.59	2.45708	99.69	2.41218	16.50	2.34937
2.69	2.44620	9.50	2.40939	17.00	2.34322
2.50	2.44087	10.60	2.40644	17.50	2,33675
3.89	2.43758	10.50	2.40331	18.00	2.32996
3.50	2.43517	11.00	2.40000		

Table 2j. Refractive Index of CVD ZnSe Specimen #2 at Discrete Wavelengths (T = 20.8 °C).

(μm) γ	ч	у (лт)	ч	(uп) ү	ц
8.55	2,66278	4.00	2.43312	11.50	2,39666
8.60	2.61409	4.50	2.43128	12.00	2.39299
0.65	2.58090	5.08	2.42949	12.50	2.38913
0.70	2.55676	5.50	2.42769	13.00	2,38505
0.75	2.53846	6.69	2.42582	13.50	2.38075
9.89	2.52415	6.50	2.42387	14.00	2.37623
8.85	2.51270	7.00	2.42181	14.50	2.37148
6.90	2.50336	7.50	2.41962	15.00	2.36647
6.95	2.49563	8, 88	2.41731	15.50	2.36121
1.69	2.48915	8.50	2.41485	16.00	2.35568
1.58	2.45721	9.90	2.41224	16.50	2.34987
2.00	2.44624	9.50	2.40947	17.60	2.34376
2,58	2.44986	10.00	2.40653	17.50	2.33735
3.66	2.43755	10.50	2.40342	18.00	2,33868
3.50	2.43513	11.00	2.40014		

^aHF=hot forged; A=.001% Er; B=.003% Er; C=.01% Er; D=.03% Er; E=.1% Er; F=.3% Er; G=1% Er; H=3% Er.

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	NaF	12.3	16.6	20.2	23.1	25.4	27.2	28.6	29.7	30.7	31.5	32.2	32.9	33.5	34.1	34.7	35.2	35.8	36.3	36.9	37.4
	LiF	8.4	12.7	16.8	20.4	23.4	26.0	28.1	29.8	31.2	32.3	33.2	34.1	34.8	35.6	36.4	37.2	38.0	38.8	39.5	40.4
	KC1	24.5	27.3	29.1	30.5	31.8	33.0	34.1	35.0	35.8	36.5	37.1	37.7	38.3	38.8	39.4	39.8	40.3	40.9	41.5	41.9
aterials	KBr	28.5	30.9	32.5	33.8	34.9	35.9	36.6	37.2	37.7	38.2	38.7	39.2	39.6	40.1	40.4	40.8	41.2	41.7	42.4	42.8
W	CaF ₂	6.7	9.1	11.1	12.8	14.1	15.2	16.2	17.0	17.7	18.3	18.7	19.1	19.4	19.7	20.0	20.4	20.8	21.3	21.7	22.2
	cdF2	6.9	12.3	14.2	15.6	16.8	17.8	18.7	19.4	20.1	20.7	21.3	21.8	22.2	22.7	23.2	23.7	24.2	24.8	25.3	25.9
	BaF ₂	9.1	11.2	12.8	14.1	15.1	15.9	16.5	17.0	17.5	17.9	18.4	18.8	19.2	19.5	19.8	20.1	20.4	20.8	21.1	21.4
Temperature (°C)		-180	-160	-140	-120	-100	-80	-60	-40	-20	0	20	40	60	80	100	120	140	160	180	200

Table 3. Linear Thermal Expansion Coefficients (10⁻⁶K⁻¹)

	NaCl		23.6	27.7	30.8	32.9	34.4	35.5	36.4	37.3	38.1	38.9	39.6	40.2	40.8	41.3	41.9	42.5	43.0	43.4	43.8	44.4
	MgF ₂	c-axis	2.90	4.45	5.95	7.39	8.86	9.82	10.86	11.74	12.47	13.07	13.70	14.09	14.54	14.94	15.32	15.67	16.00	16.33	16.67	17.00
	MgF ₂	c-axis	0.72	1.63	2.65	3.64	4.58	5.45	6.23	6.93	7.52	8.04	8.48	8.88	9.25	9.60	9.93	10.22	10.49	10.71	10.91	11.10
Materials	A1203		0.34	0.69	1.14	1.65	2.19	2.73	3.24	3.73	4.18	4.60	4.99	5.34	5.66	5.95	6.20	6.42	6.61	6.79	6.95	7.10
	ZnSe		2.6	3.7	4.6	5.2	5.6	6.0	6.4	6.7	6.9	7.1	7.3	7.5	7.6	7.7	7.8	7.9	8.0	8.1	8.2	8°3
	ZnS		1.2	2.2	3.1	3.9	4.6	5.1	5.5	5.9	6.3	6.6	6.8	7.0	7.2	7.3	7.3	7.4	7.4	7.5	7.6	7.7
	SrF ₂		7.7	10.0	11.8	13.3	14.4	15.3	16.1	16.7	17.2	17.6	17.9	18.2	18.4	18.7	18.9	19.1	19.4	19.6	19.9	20.2
cure (°C)			30	50	40	20	00	30	50	40	20	0	50	10	50	30	00	20	40	50	30	00
Temperat			-18	-1(-1-	-1,	-1(ĩ	Ĩ	7 -	1		• •	4	9	w	1(1;	1,	1(1	2(

Table 3. Linear Thermal Expansion Coefficients (10⁻⁶K⁻¹) (continued)

		Wavelength (um)
Temperature (°C)		0.4579
	dn _e /dT	dn _o /dT
-180	0.19	0.18
-160	0.36	0.32
-140	0.51	0.45
-120	0.65	0.58
-100	0.78	0.69
-80	0.89	0.79
-60	0.99	0.88
-40	1.07	0.96
-20	1.15	1.04
0	1.22	1.11
20	1.28	1.17
40	1.33	1.23
60	1.38	1.28
80	1.42	1.32
100	1.47	1.37
120	1.51	1.41
140	1.55	1.44
160	1.59	1.48
180	1.64	1.51
200	1.69	1.54
σ ^a	0.04	0.03

Table 4a. dn/dT of Al_2O_3 (10⁻⁵ K⁻¹)

Table 4b. dn/dT of BaF_2 (10⁻⁵ κ^{-1})

Tomperature (°C)			Wavele	ngth (µm)	_
Temperature (C)	0.4579	0.6328	1.15	3.39	10.6
-180	-0.78	-0.86	-0.81	-0.81	-0.73
-160	-0.92	-0.98	-0.96	-0.95	-0.85
-140	-1.04	-1.09	-1.08	-1.07	-0.96
-120	-1.15	-1.19	-1.19	-1.17	-1.05
-100	-1.24	-1.27	-1.29	-1.26	-1.13
- 80	-1.32	-1.35	-1.37	-1.34	-1.21
- 60	-1.38	-1.41	-1.44	-1.41	-1.27
- 40	-1.44	-1.47	-1.50	-1.47	-1.32
- 20	-1.49	-1.52	-1.55	-1.51	-1.37
0	-1.53	-1.56	-1.59	-1.56	-1.41
20	-1.56	-1.60	-1.62	-1.59	-1.45
40	-1.60	-1.63	-1.66	-1.62	-1.48
60	-1.63	-1.66	-1.69	-1.66	-1.51
80	-1.65	-1.70	-1.71	-1.68	-1.54
100	-1.68	-1.73	-1.74	-1.71	-1.57
120	-1.71	-1.76	-1.77	-1.75	-1.60
140	-1.75	-1.79	-1.80	-1.78	-1.63
160	-1.78	-1.83	-1.84	-1.82	-1.66
180	-1.83	-1.87	-1.88	-1.87	-1.70
200	-1.88	-1.92	-1.93	-1.92	-1.75
σ ^a	0.03	0.02	0.03	0.03	0.03

Table	4c.	dn/dT	of	CaF ₂	(10 ⁻⁵	к_1)
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		Wavelen	gth (µm)	
Temperature (*C)	0.4579	0.6328	1.15	3.39
-180	-0.39	-0.40	-0.41	-0.40
-160	-0.53	-0.54	-0.56	-0.52
-140	-0.64	-0.66	-0.68	-0.63
-120	-0.74	-0.77	-0.78	-0.73
-100	-0.83	-0.85	-0.87	-0.82
- 80	-0.90	-0.93	-0.95	-0.89
- 60	-0.95	-0.99	-1.01	-0.95
- 40	-1.00	-1.03	-1.06	-1.00
- 20	-1.04	-1.07	-1.10	-1.05
0	-1.07	-1.10	-1.13	-1.09
20	-1.10	-1.13	-1.15	-1.12
40	-1.12	-1.15	-1.18	-1.14
60	-1.14	-1.17	-1.20	-1.17
80	-1.16	-1.19	-1.22	-1.19
100	-1.18	-1.21	-1.24	-1.21
120	-1.20	-1.23	-1.26	-1.23
140	-1.22	-1.26	-1.29	-1.25
160	-1.26	-1.30	-1.32	-1.27
180	-1.29	-1.34	-1.36	-1.30
200	-1.34	-1.40	-1.41	-1.34
σ ^a	0.01	0.02	0.02	0.03

Table 4d. dn/dT of CdF_{2} (10⁻⁵ κ^{-1})

Tomporaturo	(90)		Wave	elength (µm)		
remperacure	(C)	0.4579	0.6328	1.15	3.39	
-180		-0.43	-0.56	-0.57	-0.53	
-160		-0.52	-0.64	-0.67	-0.64	
-140		-0.59	-0.72	-0.76	-0.73	
-120		-0.65	-0.75	-0.83	-0.81	
-100		-0.71	-0.84	-0.90	-0.87	
- 80		-0.75	-0.89	-0.96	-0.93	
- 60		-0.80	-0.93	-1.00	-0.98	
- 40		-0.83	-0.97	-1.05	-1.02	
- 20		-0.86	-1.01	-1.08	-1.05	
0		-0.89	-1.04	-1.12	-1.08	
20		-0.92	-1.07	-1.15	-1.11	
40		-0.94	-1.10	-1.17	-1.14	
60		-0.97	-1.13	-1.20	-1.17	
80		-1.00	-1.16	-1.23	-1.20	
100		-1.02	-1.19	-1.27	-1.23	
120		-1.06	-1.23	-1.30	-1.27	
140		-1.09	-1.27	-1.34	-1.31	
160		-1.14	-1.31	-1.39	-1.36	
180		-1.18	-1.37	-1.44	-1.42	
200		-1.24	-1.43	-1.51	-1.49	
σ ^a		0.02	0.02	0.02	0.04	

Table 4e. dn/dT of KBr (10⁻⁵ κ^{-1})

Tomporature (°C)		Wa	avelength	(µm)	
remperature (C)	0.4579	0.6328	1.15	3.39	10.6
-180	-2.85	-2.95	-3.05	-3.05	-3.06
-160	-3.30	-3.17	-3.26	-3.26	-3.24
-140	-3.19	-3.36	-3.44	-3.44	-3.40
-120	-3.33	-3.53	-3.59	-3.60	-3.54
-100	-3.46	-3.67	-3.73	-3.74	-3.66
- 80	-3.56	-3.78	-3.84	-3.85	-3.77
- 60	-3.66	-3.88	-3.94	-3.95	-3.86
- 40	-3.74	-3.96	-4.02	-4.03	-3.93
- 20	-3.81	-4.02	-4.09	-4.10	-4.00
0	-3.88	-4.08	-4.14	-4.16	-4,06
20	-3.93	-4.12	-4.19	-4.21	-4.11
40	-3.98	-4.16	-4.23	-4.25	-4.16
60	-4.03	-4.19	-4.27	-4.29	-4.20
80	-4.07	-4.23	-4.31	-4.33	-4.25
100	-4.11	-4.27	-4.35	-4.36	-4.29
120	-4.16	-4.31	-4.39	-4.40	-4.33
140	-4.20	-4.36	-4.44	-4.44	-4.38
160	-4.25	-4.42	-4.49	-4.49	-4.43
180	-4.31	-4.49	-4.56	-4.55	-4.49
200	-4.38	-4.58	-4.63	-4.62	-4.56
σ ^a	0.04	0.03	0.03	0.03	0.06

Table 4f. dn/dT of KCl (10^{-5} K^{-1})

Tomporatura	°C)	1	Wavelength	(µm)	
Temperature (0.4579	0.6328	1.15	3.39	10.6
-180	-2.26	-2.32	-2.35	-2.39	-2.33
-160	-2.44	-2.52	-2.55	-2.58	-2.50
-140	-2.61	-2.70	-2.74	-2.75	-2.65
-120	-2.76	-2.86	-2.90	-2.91	-2.80
-100	-2.90	-3.00	-3.05	-3.05	-2.93
- 80	-3.02	-3.13	-3.17	-3.17	-3.04
- 60	-3.14	-3.24	-3.29	-3.28	-3.15
- 40	-3.24	-3.35	-3.39	-3.38	-3.24
- 20	-3.33	-3.43	-3.48	-3.47	-3.33
0	-3.41	-3.51	-3.55	-3.55	-3.41
20	-3.49	-3.58	-3.62	-3.62	-3.48
40	-3.55	-3.65	-3.68	-3.69	-3.54
60	-3.61	-3.70	-3.74	-3.75	-3.60
80	-3.67	-3.76	-3.79	-3.80	-3.65
100	-3.72	-3.81	-3.84	-3.85	-3.70
120	-3.77	-3.86	-3.89	-3.90	-3.74
140	-3.82	-3.91	-3.94	-3.94	-3.79
160	-3.87	-3.96	-4.00	-3.99	-3.83
180	-3.91	-4.02	-4.05	-4.04	-3.87
200	-3.96	-4.08	-4.11	-4.09	-3.91
σ ^a	0.02	0.02	0.02	0.02	0.04

Table 4g. dn/dT of LiF $(10^{-5} \kappa^{-1})$

Memperature	(20)		V	Mavelength (1	um)
Temperature ((C)	0.4579	0.6328	1.15	3.39
-180		-0.33	-0.36	-0.38	-0.40
-160		-0.61	-0.63	-0.64	-0.60
-140		-0.85	-0.86	-0.86	-0.78
-120		-1.04	-1.05	-1.05	-0.93
-100		-1.20	-1.21	-1.21	-1.06
- 80		-1.32	-1.34	-1.34	-1.16
- 60		-1.42	-1.44	-1.45	-1.25
- 40		-1.49	-1.52	-1.53	-1.32
- 20		-1.54	-1.59	-1.60	-1.37
0		-1.58	-1.63	-1.65	-1.42
20		-1.60	-1.67	-1.69	-1.45
40		-1.63	-1.70	-1.73	-1.48
60		-1.65	-1.72	-1.75	-1.51
80		-1.67	-1.75	-1.77	-1.53
100		-1.71	-1.78	-1.79	-1.56
120		-1.75	-1.81	-1.81	-1.59
140		-1.82	-1.85	-1.84	-1.63
160		-1.90	-1.91	-1.88	-1.67
180		-2.02	-1.99	-1.92	-1.73
200		-2.16	-2.09	-1.99	-1.80
σ ^a		0.03	0.02	0.04	0.04

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()				Wavelength	(hm)			
(S) (S)	0.	4579	0.6	328	1.	15	°.	39
	dn _e /dT	dn _o /dT						
-180	0.177	0.244	0.165	0.223	0.144	0.199	0.15	0.20
-160	0.168	0.234	0.154	0.212	0.133	0.188	0.14	0.20
-140	0.159	0.225	0.144	0.201	0.122	0.177	0.13	0.19
-120	0.151	0.215	0.133	0.190	0.110	0.166	0.12	0.18
-100	0.142	0.205	0.122	0.179	0.099	0.155	0.12	0.17
- 80	0.133	0.196	0.112	0.168	0.088	0.144	0.11	0.16
- 60	0.124	0.186	0.101	0.157	0.077	0.132	0.10	0.15
- 40	0.116	0.176	0.090	0.146	0.065	0.121	0.09	0.14
- 20	0.107	0.166	0.080	0.135	0.054	0.110	0.08	0.13
0	0.098	0.157	0.069	0.124	0.043	0.099	0.07	0.12
20	0.089	0.147	0.058	0.112	0.032	0.088	0.06	0.11
40	0.081	0.137	0.048	0.101	0.020	0.077	0.05	0.10
60	0.072	0.128	0.037	060.0	0.009	0.066	0.04	0.10
80	0.063	0.118	0.027	0.079	-0.002	0.054	0.03	0.09
100	0.054	0.108	0.016	0.068	-0.013	0.043	0.02	0.08
120	0.046	0.099	0.005	0.057	-0.025	0.032	0.01	0.07
140	0.037	0.089	-0.005	0.046	-0.036	0.021	0	0.06
160	0.028	0.079	-0.016	0.035	-0.047	0.010	-0.01	0.05
180	0.019	0.070	-0.027	0.024	-0.059	-0.001	-0.02	0.04
200	0.011	0.060	-0.037	0.013	-0.070	-0.013	-0.03	0.03
ر م	0.009	0.014	0.009	0.012	0.010	0.014	0.02	0.01
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^aStandard deviation from linear fit.

		W	avelength (µm)	
Temperature (°C)	0.4579	0.6328	1.15	3.39	
-180	-2.06	-2.16	-2.22	-2.24	
-160	-2.30	-2.40	-2.48	-2.49	
-140	-2.51	-2.61	-2.70	-2.70	
-120	-2.69	-2.79	-2.89	-2.89	
-100	-2.85	-2.96	-3.06	-3.05	
- 80	-2.99	-3.09	-3.20	-3.19	
- 60	-3.11	-3.21	-3.32	-3.31	
- 40	-3.30	-3.32	-3.42	-3.41	
- 20	-3.29	-3.40	-3.51	-3.49	
0	-3.36	-3.48	-3.58	-3.57	
20	-3.42	-3.54	-3.64	-3.63	
40	-3.48	-3.60	-3.70	-3.68	
60	-3.53	-3.65	-3.74	-3.73	
80	-3.57	-3.69	-3.79	-3.78	
100	-3.62	-3.74	-3.83	-3.83	
120	-3.67	-3.78	-3.88	-3.88	
140	-3.72	-3.83	-3.93	-3.94	
160	-3.78	-3.88	-3.99	-4.01	
180	-3.84	-3.94	-4.06	-4.09	
200	-3.92	-4.01	-4.14	-4.18	
σ ^a	0.05	0.04	0.04	0.04	

Table 4i. dn/dT of NaCl $(10^{-5} \kappa^{-1})$

Table 4j. dn/dT of NaF (10⁻⁵ κ^{-1})

m	(80)			Wavelength	(µm)	
Temperature	(*C)	.4579	0.632	8 1.	.15	3.39
-180		-0.41	-0.42	-0.	.45	-0.45
-160		-0.55	-0.59	-0.	.63	-0.61
-140		-0.68	-0.74	-0	.78	-0.75
-120		-0.79	-0.86	-0.	.91	-0.86
-100		-0.88	-0.96	-1.	.02	-0.96
- 80		-0.96	-1.05	-1.	.10	-1.04
- 60		-1.02	-1.12	-1.	.17	-1.11
- 40		-1.08	-1.17	-1.	.23	-1.16
- 20		-1.12	-1.22	-1.	.27	-1.20
0		-1.16	-1.25	-1.	. 30	-1.23
20		-1.19	-1.28	-1.	. 32	-1.25
40		-1.22	-1.30	-1.	.34	-1.27
60		-1.24	-1.32	-1	.36	-1.29
80		-1.27	-1.33	-1.	. 37	-1.31
100		-1.29	-1.35	-1.	.39	-1.32
120		-1.31	-1.37	-1.	.41	-1.34
140	<u></u>	-1.34	-1.40	-1.	. 44	-1.37
160		-1.38	-1.43	-1.	.48	-1.40
180		-1.42	-1.47	-1.	.53	-1.44
200		-1.47	-1.52	-1.	. 59	-1.49
σ ^a		0.02	0.05	0	.05	0.05

Table 4k. dn/dT of $SrF_2 (10^{-5} K^{-1})$

		Wavele	ngth (µm)		
Temperature (°C)	0.4579	0.6328	1.15	3.39	10.6
-180	-0.54	-0.56	-0.55	-0.56	-0.35
-160	-0.67	-0.69	-0.69	-0.68	-0.49
-140	-0.77	-0.81	-0.81	-0.80	-0.61
-120	-0.86	-0.90	-0.91	-0.89	-0.71
-100	-0.94	-0.98	-1.00	-0.97	-0.79
- 80	-1.01	-1.05	-1.07	-1.04	-0.85
- 60	-1.06	-1.11	-1.13	-1.10	-0.90
- 40	-1.11	-1.15	-1.17	-1.15	-0.93
- 20	-1.15	-1.19	-1.21	-1.19	-0.96
0	-1.18	-1.22	-1.24	-1.22	-0.97
20	-1.20	-1.24	-1.26	-1.24	-0.98
40	-1.22	-1.25	-1.28	-1.26	-0.99
60	-1.24	-1.27	-1.29	-1.27	-0.99
80	-1.25	-1.28	-1.30	-1.28	-1.00
100	-1.26	-1.29	-1.31	-1.29	-1.01
120	-1.27	-1.30	-1.32	-1.29	-1.02
140	-1.29	-1.32	-1.33	-1.30	-1.05
160	-1.30	-1.34	-1.35	-1.31	-1.08
180	-1.32	-1.36	-1.37	-1.32	-1.13
200	-1.34	-1.39	-1.40	-1.33	-1.20
σ ^a	0.03	0.02	0.01	0.03	0.05

Table 44. dn/dT of CVD ZnS (10^{-5} k^{-1})

		Wavelength (µ	m)	
Temperature (°C)	· · · · · · · · · · · · · · · · · · ·			
	1.15	3.39	10.6	
-180	3.5	2.8	2.7	
-160	3.7	3.1	3.0	
-140	3.8	3.3	3.3	
-120	4.0	3.5	3.5	
-100	4.1	3.7	3.7	
- 80	4.2	3.9	3.8	
- 60	4.3	4.0	3.9	
- 40	4.4	4.1	4.0	
- 20	4.5	4.1	4.0	
0	4.5	4.2	4.1	
20	4.6	4.2	4.1	
40	4.6	4.3	4.1	
60	4.7	4.3	4.1	
80	4.7	4.3	4.1	
100	4.7	4.3	4.2	
120	4.8	4.4	4.2	
140	4.8	4.4	4.3	
160	4.9	4.4	4.4	
180	4.9	4.5	4.5	
200	5.0	4.6	4.7	
σ ^a	0.2	0.2	0.2	

^aStandard deviation from a third degree polynomial fit.

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Table 4m. dn/dT of CVD ZnSe (10^{-5} k^{-1})

Temperature (80)		Way	velength (µm))
Temperature (°C)	0.6328	1.15	3.39	10.6
-180	7.6	5.4	5.0	4.9
-160	8.2	5.7	5.2	5.1
-140	8.7	6.0	5.4	5.4
-120	9.1	6.3	5.6	5.5
-100	9.4	6.5	5.8	5.7
- 80	9.7	6.6	5.9	5.8
- 60	10.0	6.7	6.0	5.9
- 40	10.2	6.8	6.1	6.0
- 20	10.3	6.9	6.1	6.0
0	10.5	7.0	6.2	6.1
20	10.6	7.0	6.2	6.1
40	10.7	7.0	6.2	6.1
60	10.8	7.1	6.3	6.1
80	10.9	7.1	6.3	6.2
100	11.0	7.2	6.3	6.2
120	11.1	7.2	6.4	6.3
140	11.3	7.3	6.4	6.3
160	11.5	7.4	6.5	6.4
180	11.8	7.6	6.6	6.6
200	12.1	7.8	6.7	6.7
σ ^a	0.1	0.1	0.1	0.1

Material			Re	fractive In	dex		t _o (mm)
	$\lambda = 0.$.4579 µm	0.6328 µm	1.15 µ	mu 3.39 µm	10.6 µm	
Al ₂₀₃ a n	1.	.779					9.55
g	Г	.770					1
BaF ₂	л.	.480	1.473	1.468	1.460	1.393	13.16
caF ₂	Τ.	.438	1.433	1.428	1.415	1	13.41
cdF3	1.	.585 ^b	1.574 ^b	1.55 ^c	1.54 ^c	1	7.33
KBr ^a	г.	.577	1.557	1.542	1.536	1.525	11.83
kcl ^a	г	.502	1.488	1.478	1.473	1.454	11.87
LiF ^a	Г	.396	1.392	1.386	1.360	1	5.59
MgF ₂ a n	, L	.381	1.377	1.373	1.358	1	13.40
ц I	, L	.393	1.389	1.384	1.369	1	ł
NaCl ^a	н ц	.558	1.542	1.531	1.524	1	1
NaF ^a	Н	.329	1.325	1.321	1.312	1	12.21
SrF ₂	Г	.443	1.437	1.432	1.423	1.340	13.15
ZnS (CVD)	·	ļ		2.283	2.255	2.192	4.47
ZnSe (CVD)		-	2.591	2.475	2.436	2.403	17.49
^a See American Instit W. G. Driscoll and W	ute o	f Physics Hê Jhan (McGraw	andbook (Mc ^c v-Hill, 1978	Graw-Hill, 8) pp. 7-1.	1972) pp. 6-	12 or Handbook	t of Optics, Eds.

Data Used for Computing dn/dT

Table 5.

^DB. Krukowska-Fulde and T. Niemski, J. Crystl. Growth <u>1</u>, 183 (1967). c_{Estimated}.

Table 6. Piezo-Optic Consta Chalcogenide Glass	ants, q _{ll} a s in Units	nd $q_{12}an$ of $10^{-12}P$	d Elastic a-1	Compliance, s	12, of As ₂ S ₃ Glass and a
	ра	d ₁₁ ^b	q ₁₂ ^b	912 ⁻⁹ 11	s ₁₂ b
As ₂ s3 Glass					-18.6, -18.8 ^c
0.6328 µm	2.606	7.63	6.36	-1.27	
1.15 µm	2.452	7.64	6.54	-1.10	
10.6 µm	2.354	8.23	6.95	-1.28	
Chalcogenide Glass (Ge 33%, As 12%, Se 55%)					-12.0, -12.2 ^d -11.5 ^e
1.15 µm	2.5704	5.32	4.89	-0.43	
10.6 µm	2.4919	5.42	4.94	-0.48	
^a These values were not measu	ired in thi	s work bu	t are give	n because the	y were used to calculate the q.
b Estimated accuracy of numbe	ers from th	is work i	s ±2%.		CT
<pre>CF. W. Glaze, D. H. Blackbui 59, 83 (1957).</pre>	cn, J. S. C	smalov, D	. Hubbard,	and Mason H.	Black, J. Res. Natl. Bur. Std.
dRay Hilton, private commun:	ication	value fro	m Texas In	struments.	
^e Ray Hilton, private commun:	ication	value fro	m Bell Lab	oratories.	

	$\lambda = 0.6378 \ \mu \text{m}$	λ = 1.15 μm	λ = 3.39 µm
CaF			
q ₁₁	-0.38 ±0.03	-0.40 ±0.06	-0.52 ±0.11
9 ₁₂	1.08 ±0.03	1.09 ±0.06	1.00 ±0.11
(q ₁₁ -q ₁₂)	-1.46 ±0.01	-1.49 ±0.02	-1.51 ±0.03
9 ₄₄	0.71 ±0.01	0.72 ±0.01	0.87 ±0.06
SrF			
9 ₁₁	-0.64 ±0.04	-0.63 ±0.05	0.83 ±0.09
9 ₁₂	1.45 ±0.04	1.50 ±0.06	1.23 ±0.07
(q ₁₁ -q ₁₂)	-2.08 ±0.01	-2.13 ±0.04	-2.05 ±0.06
9 ₄₄	0.60 ±0.01	0.62 ±0.02	0.72 ±0.04
BaF			
q ₁₁	-0.99 ±0.03	-0.91 ±0.07	-0.75 ±0.07
q ₁₂	2.07 ±0.04	2.13 ±0.07	2.11 ±0.05
$(q_{11}^{-}q_{12}^{-})$	-3.06 ±0.01	-3.03 ±0.02	-2.91 ±0.08
9 ₄₄	0.95 ±0.01	0.95 ±0.01	0.99 ±0.07

Table 7a. Piezo-optic Constants of Alkaline-Earth Fluorides* (10⁻¹²Pa⁻¹)

*This work was supported in part by the Air Force Office of Scientific Research under grant No. AFOSR-78-0026.

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,	NBS	Literature
CaF ₂		
9 ₁₁	-0.38	-0.29^{a} , -0.41^{b}
q ₁₂	1.08	1.16 ^a , 1.04 ^b
(q ₁₁ -q ₁₂)	-1.46	-1.45^{a} , -1.45^{b} , -1.48^{d} ,
		-1.44^{e} , -1.47^{f}
9 ₄₄	0.71	0.70 ^a , 0.89 ^b , 0.81 ^d
<u>SrF</u> 2		
q ₁₁	-0.64	-0.58 [°]
q ₁₂	1.45	1.77 [°]
(q ₁₁ -q ₁₂)	-2.08	-2.35 [°]
9 ₄₄	0.60	0.59 [°]
BaF ₂		
q ₁₁	-0.99	-0.62 ^b
q ₁₂	2.07	2.31 ^b
(q ₁₁ -q ₁₂)	-3.06	-2.93 ^b
q ₄₄	0.95	1.06 ^b

Table 7b. Comparison of Piezo-optic Data in the Visible Region for Alkaline-Earth Fluorides $(10^{-12} \text{ Pa}^{-1})$.

 ^aF. Pockels, Lehrbuch der Kirstalloptik (B. G. Teubner, Leipzig und Berlin, 1906). (λ=0.5893 μm).
 ^bK. V. Rao, T. S. Narasimhamurty, J. Phys. Chem. Solids <u>31</u>, 876 (1970). (λ=0.5893 μm).
 ^CO. V. Shakin, M. F. Bryzhina, V. V. Lemanov, Sov. Phys. Solid State <u>13</u>, 3141 (1972). (λ=0.6328 μm).
 ^dK. S. Iyengar, K. B. Bansigar, Current Science <u>27</u>, 436 (1958).

(λ=0.5890 μm).

^eA. J. Michael, J. Opt. Soc. Am. <u>58</u>, 889 (1968). (λ=0.5461 μm).

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^tV. G. Krishna Murty, Ph.D. Thesis (Osmania University, Hyderabad, India, 1964). $(\lambda = 0.5461 \ \mu m)$.

		λ = 3.39 μm	λ = 10.6 μm
q ₁₁	$(10^{-12} \text{Pa}^{-1})$	-0.79	-0.84
9 ₁₂	$(10^{-12} Pa^{-1})$	-0.51	-0.48
9 ₄₄	(10 ⁻¹² Pa ⁻¹)	-1.07	-1.09
p ₁₁		-0.151, -0.158 ^b	-0.154
р ₁₂		-0.128, -0.132 ^b	-0.126
P ₄₄		-0.072, -0.074 ^b	-0.073
n		4.037 [°]	4.006 ^C

Table 8. Photoelastic Constants^a of Ge.

^aEstimated accuracy approximately 2%. To calculate the elasto-optic constants we used the elastic constants of H. J. McSkimin, J. Appl. Phys. <u>2</u>4, 988 (1953).

^bD. K. Biegelsen and J. C. Zesch, Phys. Rev. B <u>14</u>, 3578 (1976).

^CH. W. Icenogle, B. C. Platt, and W. L. Wolfe, Appl. Optics <u>15</u>, 2348 (1977).

λ(μm)	q _{ll}	9 ₁₂	9 ₄₄	q ₁₁ -q ₁₂	Ref.	
0.589			-4.22	1.67	a	
0.589			-4.42	1.66	b	
0.589			-4.94	1.47	с	
0.480				1.42	d	
0.589			-4.74	1.57	е	
0.633				1.81	f	
0.633	4.6 ±0.2	2.7 ±0.8	-3.9 ±0.8	1.7 ±0.4		
0.644			-4.4 ±0.2	1.9 ±0.4		
*0.633	4.6 ±0.2	2.8 ±0.2	-4.6 ±0.2	1.9 ±0.2		
*0.644			-4.7 ±0.2	1.9 ±0.1		
10.6				2.0	g	
10.6			-2.62		h	
10.6	4.3 ±0.3	2.8 ±0.3	-3.4 ±0.4	1.8 ±0.4		
10.6	4.2 ±0.2	2.6 ±0.2	-3.6 ±0.3	1.8 ±0.2		

Table 9a. Piezo-optic Constants of KCl $(10^{-12} \text{ Pa}^{-1})$.

*Nomially doped with 1.5% KI.

^aF. Pockels, <u>Lehrbuch der Kristalloptik</u> (Teubner, Leipzig, 1906), p. 408.
^bBhagavantam and Y. Krishna Murty, Proc. Indian Acad. Sci. <u>A46</u>, 399 (1957).
^cK. G. Bansigir and K. S. Iyengar, Proc. Phys. Soc. London <u>71B</u>, 225 (1958).
^dR. Srinivasan, Zeit, f. Physik <u>155</u>, 281 (1959).
^eK. V. Krishna Rao and V. G. Krishna Murty, Proc. Indian Acad. Sci. <u>64</u>, 24 (1966).
^fW. W. Wilkening, J. D. Friedman and C. A. Pitha in <u>Third Conference on High-Power Infrared Laser Windows, 1973</u>, AFCRL-TR-47-0085-1.
^gC. S. Chen, J. P. Szcznesniak, and J. C. Corelli, J. Appl. Phys. <u>46</u>, (1975).
^hC. A. Pitha and J. D. Friedman, in Proceedings of the <u>Fourth Annual</u> Conference on Infrared Window Materials, <u>1974</u>, compiled by C. R. Andrews

and C. L. Strecker.

λ (μ	ım)	р ₁₁	P ₁₂	P44	p ₁₂ /p ₁₁	Ref.
	.589			-0.0276		a
	.589	0.215	0.159	-0.024	-0.74	b
	.589	0.246	0.192	-0.0298	-0.78	с
	.633	0.21	0.15	-0.026	-0.70	
	.644			-0.029		
*	.633	0.21	0.15	-0.031	-0.72	
*	.644			-0.031		
. 10	.6	0.20	0.15	-0.023	-0.76	
*10	.6	0.19	0.14	-0.024	-0.71	

Table 9b. Elasto-Optic Constants of KCl

*Nominally doped with 1.5% KI.

^aF. Pockels, <u>Lehrbuch der Kristalloptik</u> (Teubner, Leipzig, 1906), p. 480. ^bK. S. Iyengar, Nature <u>176</u>, 1119 (1955).

^CK. V. Krishna Rao and V. G. Krishna Murty, Proc. Indian Acad. Sci. <u>64</u>, 24 (1966).

	λ = 0.6328 µm	1.15 µm	3.39 µm
$q_{11}(10^{-12} Pa^{-1})$	0.42 ±0.01	0.58 ±0.01	0.81 ±0.01
$q_{12}(10^{-12} Pa^{-1})$	2.70 ±0.01	2.80 ±0.03	2.78 ±0.02
p ₁₁	0.120 ±0.001	0.136 ±0.002	0.154 ±0.001
^p 12	0.269 ±0.001	0.281 ±0.003	0.283 ±0.001
n	1.457	1.449	1.409

Table 10. Photoelastic Constants^a of Fused SiO₂

^aThe errors are based on the standard deviation of the data and do not take into account any errors in the elastic constants.

Table 11. Photoelastic Properties of CVD ZnSe

	λ = 0.6328 µm	λ = 10.6 μm
$q_{11}(10^{-12} Pa^{-1})$	-1.44 ±0.04, -1.48 ±0.05 ^a	-1.46 ±0.07
q ₁₂ (10 ⁻¹² Pa ⁻¹)	0.17 ±0.05, 0.22 ±0.05 ^a	0.51 ±0.07
$q_{11} - q_{12} (10^{-12} Pa^{-1})$	-1.60 ±0.01	-1.97 ±0.02
p ₁₁	-0.13	-0.10
^p 12	-0.04	0.007

^aL. F. Goldstein, J. S. Thompson, J. B. Schroeder and J. E. Slattery, Appl. Optics 14, 2432 (1975).
$s'_{12} = 1/3(s_{11}+2s_{12}-1/2s_{14})$ s44 s₁₁ ^s12 BaF2 15.126 -4.708 38.941 -4.587 CaF 6.867 -1.451 29.764 -3.639Geb 9.75 -2.66 14.9 _ _ KC1^C 25.8 -3.73 158.0 Fused SiO2^d 13.16 -2.16 ___ SrF 9.877 -2.553 31.969 -3.738 -2.61^{e} -3.66^{e} ZnSe (CVD) $13.9 \pm 0.6^{e} - 4.4 \pm 0.2^{e} - -$ --

Table 12. Elastic Compliances Used in Computation of Piezo-Optic and Elasto-Optic Constants (10⁻¹²Pa⁻¹).

^aFrom tabulation by S. K. Dickinson, "Infrared Laser Window Materials Property Data for ZnSe, KCl, NaCl, CaF₂, SrF₂, BaF₂", Report No. AFCRL-TR-75-0318, PSRP # 635, Air Force Cambridge Research Laboratories, L. G. Hansom Field, Bedford, MA 01730 (1975).
^bH. J. McSkimin, J. Appl. Phys. <u>24</u>, 988 (1953).
^cS. Haussül, Zeits. fur Physik <u>159</u>, 223 (1960).
^dW. Primak and D. Post, J. Appl. Phys. <u>30</u>, 779 (1959).

^eObtained in this laboratory and used for calculating the piezo-optic constants.

NBS-114A (REV. 9-78)			
U.S. DEPT. OF COMM. BIBLIOGRAPHIC DATA	1. PUBLICATION OR REPORT NO. 2. Covit.	Accession No. 3. Recipient's Ac	cession No.
4. TITLE AND SUBTITLE		5. Publication D	ate
Optical Materials Characterization		February	1979
February 1, 1978-September 30, 1978		6. Performing Or	ganization Code
7. AUTHOR(S)		8. Performing Or	gan, Report No.
Albert Feldman, Deane Horowitz, Roy M. Waxler, Marilyn J. Dodge			
9. PERFORMING ORGANIZATION NAME AND ADDRESS		10. Project/Task/	Work Unit No.
NATIONAL BUREAU OF STANDARDS DEPARTMENT OF COMMERCE WASHINGTON, DC 20234		11. Contract/Gran	nt No.
12. SPONSORING ORGANIZATION NAME AND COMPLETE ADDRESS (Street, City, State, 2 Advanced Research Projects Agency Arlington, VA 22209		, ZIP) 13. Type of Report Final Techr 2/1/78 - 9/	rt & Period Covered nical Report
		14. Sponsoring Aj	gency Code
15 SUPPLEMENTARY NOTES			•
Decument describes a computer program' SE-185. EIPS Software Summany is attached			
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mens) Data for the thermo-optic constant (dn/dT) and the linear thermal			
expansion coefficient are given for the following materials over the temperature			
range -180 °C to 200 °C: Al O , BaF , CaF , CdF , KBr, KCl, LiF, MgF , NaCl, NaF,			
SrF. ZnS (CVD), and ZnSe (CVD). The piezo-optic constants of the following			
materials are presented: As S, glass, CaF, BaF, Ge, KCl, fused SiO, SrF, a			
chalcogenide glass (Ge 33%, Ås 12%, Se 55%) and ŽnSe (CVD).			
17. KEY WORDS (six to twelve entries; alphabetical order; capitalize only the first letter of the first key word unless a proper name;			
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